



Contribution ID: 59

Type: **Talk**

Resistively detected electron spin resonance and g factor in few-layer exfoliated MoS₂ devices

Friday 19 September 2025 11:00 (12 minutes)

MoS₂ has recently emerged as a promising material for enabling quantum devices and spintronic applications. In this context, the demonstration of resistively detected electron spin resonance (RD-ESR) and the determination and improved physical understanding of the g factor are of great importance. However, its application and RD-ESR studies have been limited so far by Schottky or high-resistance contacts to MoS₂. Here, we exploit naturally n-doped few-layer MoS₂ devices with ohmic tin (Sn) contacts that allow the electrical study of spin phenomena. Resonant excitation of electron spins and resistive detection is a possible path to exploit the spin effects in MoS₂ devices. Using RD-ESR, we determine the g factor of few-layer MoS₂ to be ≈ 1.92 and observe that the g factor value is independent of the charge carrier density within the limits of our measurements.

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Session Classification: Parallel

Track Classification: Quantum Effects, Materials Physics